

# X-Band RF Structure Fabrication at Fermilab

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The RF Technology Development group at Fermilab is working together with the NLC and GLC groups at SLAC and KEK on developing technology for room temperature X-band accelerating structures for a future linear collider. This paper describes the RF structure factory infrastructure (clean rooms, vacuum furnaces, vacuum equipment, RF equipment etc.), and the fabrication techniques utilized (the machining of copper cells / couplers, quality control, etching, vacuum brazing, cleanliness requirements etc.) for the production of FXB and FXC / FXD structures.

- Structure production factory built up in 2-1/2 years from concept to a facility with a production rate of 2 structures per month
- Semi-industrial approach---All parts made in local industry using conventional precision machining with final assembly at Fermilab
- Excellent results achieved in reproducibility of single cells as well as flat field and phase profiles for entire structures
- Structure cell-to-cell alignment and overall straightness routinely meets or exceeds mechanical requirements for NLC structures

## Fabrication Process Flow

